## WHAT IS CLAIMED IS:

## 1. A system comprising:

means for directing a gas stream into a reference channel and a measurement channel;

means for evenly restricting gas flow through the reference channel and the measurement channel;

probes located adjacent ends of the reference channel and the measurement channel and having an elongated nozzle orifice; and

means for sensing a mass of gas flow between the reference channel and the measurement channel.

## 2. The system of claim 1, further comprising:

a reference surface positioned a reference standoff from the reference probe, a gas stream from the reference probe impinges on the reference surface after traveling across the reference standoff; and

a measurement surface positioned a measurement standoff from the measurement probe, a gas stream from the measurement probe impinges on the measurement surface after traveling across the measurement standoff,

wherein the means for sensing senses a difference between the reference standoff and the measurement standoff.

## 3. The system of claim 1, further comprising:

means for controlling a mass flow rate of the gas stream positioned before the means for directing.

- 4. The system of claim 3, further comprising:

  means for reducing gas turbulence positioned after the means for controlling.
- 5. The system of claim 1, wherein the nozzle orifice has a height H which is larger than a width W.
  - 6. The system of claim 1, wherein:
    the nozzle orifice has a height H and a width W; and
    a ratio of H to W is about 2:1 to about 20:1.
  - 7. The system of claim 1, wherein:
    the nozzle orifice has a height H and a width W; and
    a ratio of H to W is about 10:1
- 8. A gas gauge proximity sensor that is provided with a gas supply during operation, comprising:
- a dividing portion that divides the supplied gas into a reference channel and a measurement channel;

flow restrictors placed in the reference channel and measurement channel;

probes respectively coupled adjacent ends of the reference channel and the measurement channel, the probes including elongated nozzle orifices; and

a mass flow sensor coupled between the reference and measurement channels that senses the mass of gas flow therebetween.

9. The gas gauge proximity sensor of claim 8, further comprising:
a reference surface positioned a reference standoff from the
reference probe, a gas stream from the reference probe impinges on the
reference surface after traveling across the reference standoff; and

a measurement surface positioned a measurement standoff from the measurement probe, a gas stream from the measurement probe impinges on the measurement surface after traveling across the measurement standoff,

wherein the mass flow sensor senses a difference between the reference standoff and the measurement standoff.

- 10. The system of claim 8, further comprising:

  a mass flow rate controller positioned before the dividing portion.
- 11. The system of claim 10, further comprising:
  a snubber located after the mass flow controller to reduce gas turbulence.
- 12. The system of claim 8, wherein the nozzle orifice has a height H which is larger than a width W.
  - 13. The system of claim 8, wherein:
    the nozzle orifice has a height H and a width W; and
    a ratio of H to W is about 2:1 to about 20:1.
  - 14. The system of claim 8, wherein: the nozzle orifice has a height H and a width W; and a ratio of H to W is about 10:1.

15. A method for proximity sensing comprising:

directing a gas stream into a reference channel and a measurement channel;

restricting gas flow through the reference channel and the measurement channel;

positioning nozzles having elongated orifices in probes adjacent ends of the reference channel and the measurement channel and proximate to a reference surface and a measurement surface; and

sensing a mass of gas flow between the reference channel and the measurement channel, to thereby determine measuring measurement channel and reference channel standoffs.

- 16. The method of claim 15, wherein the restricting gas flow step comprises evenly restricting the gas flow.
- 17. The method of claim 15, further comprising forming the elongated orifice with a height about two to about twenty times a width.
- 18. The method of claim 15, further comprising forming the elongated orifice with a height about ten times a width.